HIGH-SPEED LASER STRUCTURING OF ELECTRODES

What We Do: Empower advanced battery production by employing high-speed laser micro and nanostructuring technologies for 3D electrode architectures fabrication.

Our Edge: Our unique technology combines high-energy pulsed ultrashort laser systems, beam shaping, and multi-beam micro and nanostructuring technologies, achieving record productivity in nanostructuring of electrodes.

Benefits of Laser-Structured Electrodes

Enhanced Active Area

- Promote stable electrodes
- Improve catalyst adhesion

Improved and Stable Performance

- · Sustain performance under extended operating times
- Lower Area Specific Resistance (ASR)
- · Reduce overpotential for improved performance
- Maintain consistent medium-term performance

Efficient Energy Utilization

- · Enable better energy utilization
- · Increase battery efficiency and lifespan

Versatility and Adaptability

· Adapt to various types of batteries, including lithium-ion and zinc-air

Environmental Considerations

- · Potential to reduce the environmental impact of battery production
- Lower long-term production costs

Areas of Application











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FOOD AND PHARMACEUTICAL

HiLASE Centre · Institute of Physics of the ASCR, v.v.i. · Za Radnici 828, CZ-25241 Dolni Brezany Solutions@hilase.cz · in hilase-centre · → (+420) 314 007 717 / 314 007 758 · 🔅 www.hilase.cz







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Adhesion Details

HiLASE PERLA Laser System An Ytterbium-based DPSSL laser system capable of operating at different repetition rates, providing flexibility in performance.

Spatial Light Modulator (SLM) Based Beam Shaping Module FBS G3 Equipped with a spatial light modulator and galvanometer scanner, enabling fast and efficient machining of complex 3D parts.

Record Nanostructuring Productivity A unique combination of the laser system with the SLM achieves record nanostructuring productivity of over 1900 cm²/min with structure detail below 750 nm.